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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/796,274	03/10/2004	Paul Rich	WLJ.103	9386	
75	590 01/10/2006		EXAM	INER	
VOLENTINE FRANCOS, P.L.L.C.			ESTRADA, MICHELLE		
Suite 150	•				
12200 Sunrise Valley Drive			ART UNIT	PAPER NUMBER	
Reston, VA 20191			2823		
			DATE MAILED, 01/10/200	DATE MAILED: 01/10/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

	L Application No.	Applicant(c)
•	Application No.	Applicant(s)
Office Assistant Communication	10/796,274	RICH ET AL.
Office Action Summary	Examiner	Art Unit
	Michelle Estrada	2823
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D/ - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period v - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).
Status		
1) ☐ Responsive to communication(s) filed on 31 O 2a) ☐ This action is FINAL. 2b) ☐ This 3) ☐ Since this application is in condition for alloware closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro	
Disposition of Claims		
4)	wn from consideration.	
Application Papers		
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	epted or b) objected to by the I drawing(s) be held in abeyance. Sec ion is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage
Attachment(s)	□	(070 440)
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	

Application/Control Number: 10/796,274

Art Unit: 2823

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 11 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakamura et al. (2004/0238891) in view of the Matsumoto et al. (6,451,690).

Re claim 11, Nakamura et al. disclose forming a tungsten/tungsten nitride stack on a wafer including sputtering a tungsten nitride film on a wafer and sputtering a tungsten film on the tungsten nitride film (Page 3, [0038]), wherein the wafer is on a platen and the platen temperature is maintained substantially the same for the two sputter processes.

Nakamura et al. do not disclose wherein the two sputtering processes are performed in a single chamber using a single target.

Matsumoto et al. disclose forming a tungsten/metal nitride stack on a wafer including sputtering a metal nitride film on a wafer and sputtering a tungsten film on the metal nitride film; wherein the two sputtering processes are performed in a single chamber using a single target (Col. 5, lines 25-37).

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Nakamura et al. and Matsumoto et al. to enable the sputtering Art Unit: 2823

processes conditions of Matsumoto et al. to be performed in the process of Nakamura et al. to improve the throughput.

Re claim 15, The combination of Nakamura et al. and Matsumoto et al. would yield in a gate structure formed by the method of claim 11.

Allowable Subject Matter

Claims 1-3, 5-7, 9, 10, 13 and 14 are allowed.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michelle Estrada whose telephone number is 571-272-1858. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 571-272-2800.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only.

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Patent Examiner Art Unit 2823

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